Modified Stillinger-Weber Interatomic Potentials

Molecular dynamics simulation of vapor deposition of elemental and compound materials

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- 1. X. W. Zhou and H. N. G. Wadley, Computational Materials Science, in press, 2007.
- 2. X. W. Zhou and H. N. G. Wadley, Computational Materials Science, in press, 2007.

Objectives

- 1. Understanding better the Stillinger-Weber potentials.
 - why we decide to use it?
 - where it may not be accurate?
- 2. Extending the Stillinger-Weber potentials.
 - dc, sc, bcc, and fcc elements.
 - B1, B2, and B3 binary compounds.
- 3. Simulating growth and oxidation of materials using molecular dynamics methods.
 - case studies: Si, Po, Fe, Ni, Mg, and MgO.

Cohesive Energy



Published Growth Simulation Using SW Potential



- 1. G. H. Grein, J. P. Faurie, V. Bousquet, E. Tournie, R. Benedek, and T. de la Rubia, *J. Cryst. Growth*, 178, 258(1997).
- 2. G. H. Gilmer, and C. Roland, Appl. Phys. Lett., 65, 824(1994).
- 3. B. Strickland, and C. Roland, *Phys. Rev. B*, **51**, 5061(1995).
- 4. H. W. Lu, and J. Y. Feng, *Modelling Simul. Mater. Sci. Eng.*, **8**, 621(2000).

Published Growth Simulation Using TF Potential



Growth of InAs on (110) GaAs surface. –from Ref. [1].

All the potentials listed on this slide do not correctly predict the crystalline growth. The Tersoff Si potential, Ref. [2], for instance, predicts the crystalline growth only at temperature above 2200 K.

- 1. M. Nakamura, H. Fujioka, K. Ono, M. Takeuchi, T. Mitsui, and M. Oshima, J. Cryst. Growth, 209, 232(2000).
- 2. J. Tersoff, *Phys. Rev. B*, **39**, 5566(1989). for Si.
- 3. P. A. Ashu, J. H. Jefferson, A. G. Cullis, W. E. Hagston, and C. R. Whitehouse, *J. Cryst. Growth*, **150**, 176(1995). for GaAs.
- 4. R. Smith, *Nucl. Instru. Meth. B*, **67**, 335(1992). for GaAs.

Formalisms

Stillinger-Weber potential:

$$E_{c} = \frac{1}{2N} \sum_{i=1}^{N} \sum_{j=i_{1}}^{i_{N}} \phi(r_{ij}) + \frac{1}{2N} \sum_{i=1}^{N} \sum_{j=i_{1}}^{i_{N}} \left[\left(\sum_{\substack{k=i_{1}\\k\neq j}}^{i_{N}} u(r_{ik}) \cdot g(\cos \theta_{jik}) \right) \cdot u(r_{ij}) \right]$$

Tersoff potential:

$$E = \frac{1}{2N} \sum_{i=1}^{N} \sum_{j=i_1}^{i_N} V_R(r_{ij}) + \frac{1}{2N} \sum_{i=1}^{N} \sum_{j=i_1}^{i_N} \overline{B_{ij}} \cdot V_A(r_{ij})$$

$$\phi(r) = A \cdot S \cdot \left(\frac{\sigma}{r}\right)^4 \cdot \exp\left(\frac{\sigma}{r - r_c}\right) - A \cdot \exp\left(\frac{\sigma}{r - r_c}\right) \qquad g\left(\cos\theta\right) = \left(\cos\theta + \frac{1}{3}\right)^2$$

 $u(r) = C \cdot \exp\left(\frac{\gamma}{r - r_c}\right)$

Keys: Fit f for the equilibrium structure, adjust u to ensure "phase transferability"

Crystal Analysis

x [100]





Angular Function



$$g_i(\cos\theta) = g_{o,n} + \chi_n \cdot (\cos\theta - \cos\theta_n)^2, \quad x_{\min,n} \le \cos\theta \le x_{\max,n}, \quad n = 1, 2, \cdots$$

Model Predictions of Properties

Examples: cohesive energy, lattice constant, bulk modulus, and other elastic constants for four elements

	Data type	Cohesive energy, E _c (eV/atom)	Lattice constant, a (Å)	Elastic constants (eV/Å ³)			
Element				В	C ₁₁	C ₁₂	C ₄₄
	Predicted	-4.670	5.431	0.612	1.006	0.415	0.678
Si	Target	-4.670	5.431	0.612	1.036	0.400	0.498
	Predicted	-1.463	3.280	0.352	1.056	0.000	0.266
Po	Target	-1.463	3.280	0.352	0.706	0.175	0.266
	Predicted	-4.320	2.866	2.108	2.809	1.757	1.757
Fe	Target	-4.320	2.866	1.054	1.413	0.875	0.725
	Predicted	-4.450	3.520	2.820	4.487	1.987	2.225
Ni	Target	-4.450	3.520	1.128	1.541	0.922	0.779

$$\phi(r) = A \cdot S \cdot \left(\frac{\sigma}{r}\right)^4 \cdot \exp\left(\frac{\sigma}{r - r_c}\right) - A \cdot \exp\left(\frac{\sigma}{r - r_c}\right)$$

Problems of Exactly Fitting the Bulk Modulus

Example: fcc Ni



Comparison SW and Morse Pair Potentials

SW:
$$\phi(r) = A \cdot S \cdot \left(\frac{\sigma}{r}\right)^4 \cdot \exp\left(\frac{\sigma}{r - r_c}\right) - A \cdot \exp\left(\frac{\sigma}{r - r_c}\right)$$

Morse: $\phi(r) = D_e \cdot \exp\left[-2(r-r_e)\right] - 2D_e \cdot \exp\left[-(r-r_e)\right]$



Si data from: X. W. Zhou and H. N. G. Wadley, Computational Materials Science, in press, 2006.

Simulation of Growth: Elemental Systems

Adatoms are randomly injected to the surface at a temperature of 650 K.



Simulation of MgO Growth

Identical fluxes of Mg and O vapor atoms are randomly injected to the MgO surface at a temperature of 650 K.



Simulation of Growth: Compound Systems

An (111) Mg surface is exposed to oxygen environment at a temperature of 800 K.



Conclusions

- 1. Stillinger-Weber potentials only target the equilibrium crystal structure. The energy and crystal geometry of other phases cannot be precisely predicted. As a result, they should not be used in the potential parameterization.
- 2. Extremely easy to parameterize for the equilibrium crystal phase to have the lowest cohesive energy.
- 3. The current pair function forms have nice cutoff, but are not physical and cannot well predict bulk moduli for non- diamond cubic or zinc-blende crystals. This can be easily improved.
- 4. Successfully used to simulate the growth and oxidation of variety materials: Si, Po, Fe, Ni and MgO.
- 5. Stillinger-Weber potentials do not capture energies of molecular gases and therefore cannot reveal the effects of flux ratio of these gases during surface growth.
- 6. Virtual cutoff distance can be reduced to accelerate simulations without affecting the results.